

DOCUMENTATION OF RISIS DATASETS - RISIS Patent Database

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RISIS



RESEARCH INFRASTRUCTURE FOR SCIENCE AND INNOVATION POLICY STUDIES

DOCUMENTATION OF RISIS DATASETS RISIS Patent

Written by P. Laurens (UPEM), P. Larndo (UPEM) 07/2019

Risis Patent was constructed by L. Villard and J.P. Ospina Delgado (UPEM). P. Laredo, P. Laurens, L.D. Medina and A. Schoen have also contributed







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1 Basic Characteristics

The RISIS Patent database derives from the EPO PATSTAT. The database is designed for the analysis of technological knowledge creation, using patent as a proxy. It thus focuses on priority patents that represent the creation of new knowledge, while other non-priority patents describe either technical ameliorations or market extensions and are mobilised as indicators of the importance of the priority patent. We shall explain in the documentation an important enrichment made to insure a good coverage of the priority patents, that is the reintroduction in the database of so-called artificial priority patents (13,3% of total priority patents).

Overall 16,406,977 priority patents of inventions were applied for from 2000 to 2015¹. They include 39,761,538 inventors².

As we are first interested in tracking knowledge creation, (more than the extension of the knowledge protection), the dates that matter, are the first filing date (when the organisation is applying for a priority patent, i.e. the first filing for a new invention) and the first publication date, as the time stamp of when the knowledge has been created is an important information for research..

Besides the date of the filing and the office where the patent was first filed, we specifically consider in RISIS Patent 5 core attributes on patents:

- Their content, using textual pieces of information such as the patent titles, the patent abstracts³ and a text aggregating the definition of the patent IPC (International Patent Classification) codes. Based on the definition of some 75000 IPC classes provided for by PATSTAT, the latter builds a rich vocabulary enriching widely the content available for semantic analyses.
- Their technological content using the standard technology classification: (IPC subclasses, aggregation of IPC codes) by technological domains, fields or subfields. Patent allocation in the different classifications is realised on a fractional count basis according to their IPC.
- The geographical location of inventive activities. As we are interested in the geography of knowledge creation, we focus on inventors addresses (instead of using applicants addresses which would more capture commercialisation). We shall explain the difficulties associated with this approach and the extensive developments made. These addresses are geocoded and associated to functional areas (urban and rural) worldwide mobilizing the RISIS CORTEXT geocoding service.
- The legal organisations that apply for patents (the applicants). We use available information proposed by PATSTAT for the harmonisation of applicants' names and allocation of assignee sectors. But one central effort is to articulate it and mobilise the extensive work done by other RISIS databases to identify worldwide large firms (CIB), European fast growing midsized firms (Cheetah), European venture capital backed start-up firms (VICO) and European

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¹ i.e. ipr_type = PI in PATSTAT

² Corresponding to 9,096,610 distinct person_id and 6,057,257 distinct doc_std_name_id.

³ Translation in English for titles and abstracts that remain in their native language will be included in a next release of RISIS Patent.





public research organisations (ORGREG covering universities, PROs and research hospitals). This will be implemented step by step in the next RISIS Patent release.

- Characteristics linked to the value of the patent: In this context, the database provides information on whether the patent was granted or not, as well as the size of patent families, i.e. the number of different applications for a given invention (or group of linked inventions), which tells something about the interest of applicants for developing and protecting the knowledge; moreover, the presence in 5 world-level patent offices (EPO, USPTO, Japan Patent Office, Korean Patent Office, China Patent Office) tells something about the potential for future markets; and citations they have received indicate knowledge flows to other inventions and therefore its value for further technological development.

The coverage of the database is 2000-2015 (using the PATSTAT 2017 Edition April as a source). The first release is in September 2019. A second one will occur in spring 2020. The database will be only periodically updated using new PATSTAT version (the next update should be in 2021). The database is developed and maintained by UPEM. The database is located on the servers of UPEM at Marne La Vallee, France.

2 Database content

2.1 Definition and description of observations

As a proxy for knowledge creation, the unit of observation is a priority patent application, i.e. the very first patent application, anywhere in the world to protect an invention. The priority date is used to determine the novelty of the invention, which implies that it is an important concept in patent procedures. For statistical purposes, the priority date is the closest date to the date of invention.

We consider only applications of priority patents of invention (i.e. $ipr_type = Pl$ in PATSTAT)⁴. Accordingly, the database covers priority patents applied since 2000, whether or not they turn later into granted patents. The 16,406,977 priority patents are distributed across three main types of applications:

-a large category of patents A, i.e. regular patents following the Paris convention (appln kind =A): 15,030,308 applications,

-provisional patent, i.e. preliminary and temporary patents proposed in some patent offices like USPTO (appln_kind = P) : 1,146,128 applications,

-PCT patent in the international phase (appln_kind = W): 224 188 applications.

We also include priority patents tagged as artificial priority patents due to priorities in PATSTAT (12,7% of the overall priorities but 41,1% in the priorities applied at the US patent office and 33,8% the priorities applied at the EPO). As these latter documents only contain the filling date and patent office in PATSTAT, we have devised a complex method to fill the information on their applicants, inventors, title, IPC classes. (see Appendix 1 for the description of technical developments and share of applications by patent offices and Laurens et al., 2018⁵ for the importance of such an enrichment).

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⁴ Other types of patent are: Utility Models (ipr_type = 'UM') and Design patents (ipr_type = 'DP').

⁵ Laurens et al., 2018, "The artificial patents in the PATSTAT database: how much do they matter when computing indicators of internationalisation based on worlwide priority patents?" Scientometrics 114,1, 91-112.





As we are interested in the development of organised knowledge, we focus only on patents taken by organisations, i.e. legal persons (firms, university, NGO); therefore, the 2,373,199 patents (15 % of the patent applications) applied only by natural persons have been discarded. The resulting perimeter of the current version of the database is 13,333,585 patent applications.

When a co-application of patent includes both legal and natural persons, the patent is maintained in the database with its legal applicant only. This is the case for 1,252,657 patent applications, i.e. 8 % of the overall applications.

In order to do so, we have first devised a method to recognise applicants that are natural persons, and we take them out from the database. In 0.8% of the case, the type of applicant (legal or person) could not be determined. These applicants are tagged as Unknown (see Appendix 2 for the technical developments).

A fractional counting was employed to calculate the number of legal applicants in a patent applications: All applicants with a fract_applt below 1 have legal co-applicants.

2.2 Data acquisition and processing (e.g. data cleaning)

a) Data sources

The RISIS Patent database uses four sources of information. It builds first and mainly on the PATSTAT public database from EPO (version April2017). Secondary sources are used for complementing this main data source, mainly for filling addresses that are void in PATSTAT:

- REGPAT data base (provided freely on request) from OECD that presents patent data that have been linked to regions according to the addresses of the applicants and inventors,
- Data from the French patent office (INPI) for filling addresses in patent applications from INPI that are missing in PATSTAT,
- Data from the Japanese patent office (JPO) for filling addresses in patent applications from JPO that are missing in PATSTAT.

b) Data processing

The principal data processing includes:

1- Data enrichment steps of the initial raw patent data

- Filling missing addresses, missing information on IPC (international patent classification) and on inventors and applicants using the REGPAT, INPI and JPO data (see above),
- Re-allocation of addresses information contained in other fields (persons names)
- Propagating information (using fuzzy matching) within patent families for missing info on applicants and inventors,
- Propagating information for filling information in artificial applications using other applications within patent families,

2- Addition of complementary information





- Identifying priority patent applications, the artificial priority applications, singletons (i.e. lone patent applications in an Inpadoc family), transnational patents (applied in at least 2 patent offices),
- Identifying the type of applicants (legal/person/unknown),
- Extraction, cleaning and harmonisation of country information for applicants and inventors by analysing respectively applicants and inventors addresses,
- Addition of geographical classification on continent for applicants and inventors,
- Geocoding of addresses (applicants and inventors),
- Attribution of the urban area for the address based on geocoded data,
- Addition of information on technology classification at three levels (5 domains, technology fields according to WIPO classification in 35 categories and technology subfields according to IFRIS classification in 400 categories),
- Addition of the IPC definition (full textual information),
- Extraction of year of application from the date of application,
- Addition of tags characterising the patent applications with no inventors, the patent applications with no IPC,
- Fractional counting at the patent application level according to different dimensions: technological classifications, number of applicants, number of inventors,
- Calculation of the priority patent geographical coverage (based on patent families): number of patent offices, applications in the IP5 patent offices (EPO, USPTO, JPO, SINO, KINO), number of patents in the docdb and inpadoc families of the priority applications.

3- Filtering of patents

We select only priority patents of inventions from 2000 to 2015 with at least one legal applicant (including artificial priority applications).

4- Creation of the final tables

The final tables includes data on priority patents only and covering 6 dimensions: Basic patent data, Geographical data on inventors and applicants, Institutional data on applicants, Technological data based on classification, Textual data, Patent value data.

2.3 Information on all variables/indicators

For each priority patent application, the database gives:

- patent ID number
- date of first filing
- country of first filing
- date of first publication
- date of first granting
- title
- abstract
- IPC categories mentioned: their number and their language description: as many variables as IPC categories, only one linguistic description
- whether the patent is a singleton (only one single application)or not





- whether the patent is a transnational patent, i.e. was the priority application extended in at least a foreign country) or not
- size of the DOCDB family
- size of the INPADOC family
- presence (directly or through extension) in the 5 core offices (so called IP 5 families) (5 variables Y/N per office)
- For each applicant: the applicant natural name and its ID; the applicant standardised name and its ID; the applicant standardised name by Leuven and its ID; the applicant RISIS standardised name and its ID when available
- For each inventor: same variables as for applicants
- For each applicant: presence or not in the CIB database, name and ID of the group firm (GUO), presence or not in the CHEETAH database, ID of the Cheetah firm, presence or not in the VICO database and ID of the VICO firm; presence in firmreg database and Firmreg ID.
- For each applicant: The applicant address, The applicant geo coordinates, the applicant urban and rural cluster it belongs to
- For each inventor: the inventor address, the inventor geo coordinates, the inventor urban or rural cluster he/she belongs to

2.4 Sectorial, temporal and geographical coverage

- Sectorial coverage

Sectors of the legal applicants

In the current RISIS Patent database, we rely on the sectorial information provided in the raw PATSTAT database⁶. Data are shown in the table below.

Table 1: Industrial sectors of priority patent applicants

Sector of legal applicants	Number of applicants	Share of applicants
COMPANY	615,724	82,6%
COMPANY GOV NON-PROFIT	4,764	0,6%
COMPANY GOV NON-PROFIT UNIVERSITY	8	0,0%
COMPANY HOSPITAL	87	0,0%
COMPANY UNIVERSITY	112	0,0%

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⁶ Harmonizing names and allocation of assignee sectors in Patstat raw data was done by ECOOM (K.U. LEUVEN; http://www.ecoom.be/en/EEE-PPAT).





GOV NON-PROFIT	21,368	2,9%
GOV NON-PROFIT HOSPITAL	3	0,0%
GOV NON-PROFIT UNIVERSITY	1,406	0,2%
HOSPITAL	1,233	0,2%
INDIVIDUAL	13,571	1,8%
UNIVERSITY	17,041	2,3%
UNIVERSITY HOSPITAL	2	0,0%
UNKNOWN	70,548	9,5%
TOTAL	745,879	100,0%

Technological coverage of patents

There is a thematic coverage of the technology that the patents protect linked to the IPC classification of patents (one patent can belong to multiple classes). Patents are allocated to fields of technology on a fractional count basis according to their IPC. Building on the correspondence table developed by ISI FhG for WIPO - which defines domains (5) and fields (35) of technology, an additional level of sub fields (401) of technology was developed (See Appendix 3 on technological fields).

The distributions of patents with the domains and the technological fields are shown below.

Table 1: Domains of technology of priority patent applications

Domain code	Domain name	Number of patents (fractional counting)	Share of patents
TD01	Electrical engineering	4,524,707	34,6%
TD02	Instruments	1,949,793	14,9%
TD03	Chemistry	2,692,039	20,6%
TD04	Mechanical engineering	2,922,951	22,3%
TD05	Other fields	994,353	7,6%
Total		13,083,843	100,0%

Table 2: Technology fields of priority patent applications

Field code	Field_name	Number of patents (fractional counting)	Share of patents
TF01	Electrical machinery, apparatus, energy	955,139	7,3%
TF02	Audio-visual technology	583,762	4,5%
TF03	Telecommunications	434,316	3,3%
TF04	Digital communication	562,319	4,3%
TF05	Basic communication processes	122,523	0,9%
TF06	Computer technology	1,057,050	8,1%
TF07	IT methods for management	219,395	1,7%
TF08	Semiconductors	590,203	4,5%





AND IN	NOVALION POLICY STUDIES		
TF09	Optics	553,166	4,2%
TF10	Measurement	670,222	5,1%
TF11	Analysis of biological materials	69,652	0,5%
TF12	Control	248,645	1,9%
TF13	Medical technology	408,108	3,1%
TF14	Organic fine chemistry	238,838	1,8%
TF15	Biotechnology	198,223	1,5%
TF16	Pharmaceuticals	405,962	3,1%
TF17	Macromolecular chemistry, polymers	242,901	1,9%
TF18	Food chemistry	200,591	1,5%
TF19	Basic materials chemistry	323,096	2,5%
TF20	Materials, metallurgy	329,110	2,5%
TF21	Surface technology, coating	237,130	1,8%
TF22	Micro-structural and nano-technology	24,341	0,2%
TF23	Chemical engineering	278,038	2,1%
TF24	Environmental technology	213,809	1,6%
TF25	Handling	359,404	2,7%
TF26	Machine tools	384,030	2,9%
TF27	Engines, pumps, turbines	332,934	2,5%
TF28	Textile and paper machines	289,628	2,2%
TF29	Other special machines	381,389	2,9%
TF30	Thermal processes and apparatus	240,448	1,8%
TF31	Mechanical elements	374,598	2,9%
TF32	Transport	560,520	4,3%
TF33	Furniture, games	332,844	2,5%
TF34	Other consumer goods	209,155	1,6%
TF35	Civil engineering	452,353	3,5%
Total		13,083,843	100,0%

- Temporal coverage

The database of this first release (summer 2019) covers patent applications from 2000 to 2015 (based upon PATSTAT2017 Version April). It is most likely that years 2016 and 2017 are still only partially filled. It includes 13,333,585 applications of priority patents

The number of PI priority patents applied every year is shown below. It has doubled during this 15 years. Year 2015 is probably not fully completed

Table 3: Number of priority patent applications over time

Filing year	Number of Pl priority patent applications
2000	663,553
2001	665,235
2002	655,632





71170 111170 771101171 01101 0100120			
2003	670,504		
2004	701,440		
2005	736,782		
2006	751,220		
2007	779,526		
2008	805,129		
2009	778,235		
2010	833,469		
2011	908,657		
2012	1,051,103		
2013	1,172,448		
2014	1,220,297		
2015	(940,355) ⁷		
Total	13,333,585		

- Geographical coverage

Geography of the PI protection

The data cover all priority patent applications worldwide, i.e. at all regional and national offices in the world (see table below). More than 50% of the priority applications are applied for at the Japanese or Chinese ones. The IP5 patent offices (US, EP, JP, CN, KR) cumulate together 87,8% of the applications.

Table 4: Number of priority patent applications and share of artificial priorities according to the patent offices

Patent office	Number of PI patent applications	Distribution of PI patent applications	Share of artificial priority patents
Total	13,333,585	100,0%	12,7%
JP	4,421,954	33,2%	9,5%
CN	3,205,972	24,0%	1,0%
US	2,206,472	16,5%	41,1%
KR	1,265,278	9,5%	3,9%
DE	610,583	4,6%	9,9%
EP	278,071	2,1%	33,8%
TW	215,233	1,6%	2,3%
GB	193,746	1,5%	0,5%
FR	175,357	1,3%	3,0%
RU	174,021	1,3%	0,6%

⁷ This number of patents in 2015 should be considered with caution. It should not be interpreted as a decreasing trend of patent application but rather as a lack of completedness of the database for this very year.





IT	92,378	0,7%	7,3%
AU	79,895	0,6%	31,2%
SE	34,249	0,3%	15,6%
PL	31,203	0,2%	1,2%
BR	27,072	0,2%	1,7%
ES	26,643	0,2%	5,4%
IN	24,830	0,2%	76,9%
NL	23,623	0,2%	12,5%
FI	22,686	0,2%	4,9%
UA	19,976	0,1%	2,4%
Other	204,343	1,5%	

After a first priority patent application for a new invention, the IP protection can be further extended in several geographical countries considered as future market. The following tables give information on the geography of the patent protection of a given priority patent using data available in its Inpadoc family. Most of the patents, for a given invention are applied in a single patent office and only 27% of the priority patents are transnational, i.e. further extended in another patent office (20% from 2 to 5 patent offices).

Table 6: Number of patent offices where patents are applied for a given invention

Number_of distinct patent offices in the inpadoc family	Number of patents	priority	Share of priority patents
1	9,775,432		73,3%
2	1,146,279		8,6%
3	689,257		5,2%
4	544,891		4,1%
5	389,437		2,9%
More than 5	788,289		5,9%
Total	13,333,585		100,0%

40% of the inventions are protected in Japan (either in the first or secondary subsequent filings), 36% in China, 31 in US, 16% at EPO, 15% in Korea. 19% of the families include a PCT patent⁸.

Table 7: Number and share of patents (priority or secondary applications) applied in the five largest patent offices (IP5 patent offices)

Content of Inpadoc family ⁹	Number of priority patents	Share of priority patents
Total	13,333,585	100%
US application	4,080,093	31%
EP application	2,170,029	16%

⁸ The Patent Cooperation Treaty (PCT) provides a unified procedure for filing patent applications to protect inventions in each of its contracting states. A patent application filed under the PCT is called an international application, or PCT application.

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⁹ Only ipr_type: PI is considered in inpadoc family.





JP application	5,362,865	40%
KR application	1,963,807	15%
CN application	4,733,883	36%
W application	2,541,004	19%
Transnational patent	3,558,153	27%

Geography of the inventions

In 80% of the patents, the location of the inventions (inventors geographical location) is known and in 84.7% of them, the location of the applicant is indicated. The shares of patents according to the inventors and applicants addresses are shown is the tables below.

Table 8: Number of priority patent applications according to the country of inventors

Country of inventors	Number of patent applications with inventor from the country	Share of patent applications with inventor from the country
Total number of patents	13,333,585	
JP	4,443,833	33,3%
Unknown	2,661,403	20,0%
CN	2,435,340	18,3%
US	1,876,575	14,1%
KR	1,253,756	9,4%
DE	731,139	5,5%
TW	365,109	2,7%
FR	241,406	1,8%
RU	150,593	1,1%
GB	128,201	1,0%
CA	113,051	0,8%
IT	108,064	0,8%
NL	86,513	0,6%
CH	76,174	0,6%
SE	64,687	0,5%
IN	60,865	0,5%
IL	46,406	0,3%
AU	42,298	0,3%
FI	41,556	0,3%
ES	40,691	0,3%
AT	35,786	0,3%





Table 9: Number of priority patent applications according to the country of applicants

Country of applicant	Number of patents with applicant from the country	Share of patents with applicant from the country
Total number of patent	13,333,585	
JP	4,461,707	33,5%
Unknown	2,168,294	16,3%
US	1,910,643	14,3%
CN	1,419,625	10,6%
KR	1,260,410	9,5%
DE	697,682	5,2%
TW	317,614	2,4%
FR	234,668	1,8%
GB	185,910	1,4%
RU	144,748	1,1%
NL	103,813	0,8%
СН	100,988	0,8%
CA	94,427	0,7%
SE	77,818	0,6%
IT	70,122	0,5%
IL	55,721	0,4%
FI	47,115	0,4%
AU	41,071	0,3%
IN	38,090	0,3%
ES	36,146	0,3%
PL	32,018	0,2%

2.5 Quality and accuracy of data

Checking the data quality is not be carried out on the initial PATSTAT raw data but on the further improvements done at LISIS to produce RISIS Patent. It includes tests of completedness and consistency.

Tests of completedness

1- Patent applications without any information on applicants (all applicants)

Table 10: Share of priority patent applications without any information on the applicants according to the patent office for the 25th largest patent offices





Patent office	Number of PI patent applications	Share of PI patent applications without any applicant*
JP	4635006	1,3%
CN	4047877	2,2%
US	3004923	7,1%
KR	1700903	5,1%
DE	699263	0,1%
RU	380052	28,5%
GB	302037	0,0%
EP	291545	0,4%
TW	256584	1,9%
FR	207753	0,1%
IT	132644	0,2%
AU	107909	0,6%
BR	59205	3,1%
PL	43726	0,5%
SE	42100	0,9%
CA	40058	0,0%
ES	37619	0,1%
UA	34780	13,6%
IN	31792	3,1%
NL	30793	0,1%
FI	28474	0,1%
AT	21555	0,1%
СН	20595	0,4%
DK	16739	0,5%
IL	15631	3,2%
Total	16406977	3,5%

^{*} appln_id not in table applt_address_ifris

2- Patent applications with legal applicants without any information inventors nor IPC codes

Table 11: Share of priority patent applications with legal applicants without any information on inventors or IPC codes according to the patent office for the 25th largest patent offices

Patent office	Number of PI patent applications	Share of PI patent applications without any inventor*	Share of PI patent applications without any IPC codes**
Total	13333585	1,5%	1,8%





JP	4421954	0,0%	0,1%
CN	3205972	0,1%	0,3%
US	2206472	0,1%	0,3%
KR	1265278	0,0%	0,8%
DE	610583	2,8%	0,1%
EP	278071	2,2%	0,2%
TW	215233	3,7%	1,8%
GB	193746	67,8%	53,6%
FR	175357	0,7%	0,5%
RU	174021	0,7%	0,0%
IT	92378	1,1%	64,6%
AU	79895	22,6%	17,7%
SE	34249	1,1%	1,9%
PL	31203	0,2%	0,5%
BR	27072	0,4%	1,4%
ES	26643	0,2%	0,2%
IN	24830	0,4%	1,6%
NL	23623	0,3%	0,1%
FI	22686	1,9%	3,8%
UA	19976	2,0%	0,1%
CA	19870	1,1%	0,2%
CH	16208	1,1%	0,2%
AT	15121	42,4%	4,0%
DK	14990	0,9%	0,5%
IL	10431	73,2%	25,0%

^{*} appln_id not in table invt_address_ifris

3- Patent applications with legal applicants with missing country of the inventors or missing geocoded address of inventors

Table 12: Share of priority patent applications with legal applicants with information on the country of the inventor or with geocoded address of inventors according to the patent office for the 25th largest patent offices

Patent office	Nber of PI patent applications	Share of PI patent applications with at least one inventor without assigned country*	Share of PI patent applications with at least one inventor without geocoded address*
Total	13333585	21,5%	41,9%
JP	4421954	4,6%	14,9%
CN	3205972	69,8%	82,1%
US	2206472	0,4%	8,2%

^{**} appln_id not in table ipc_technology_frac_ifris





KR	1265278	4,6%	75,2%
DE	610583	3,1%	41,1%
EP	278071	2,7%	12,6%
TW	215233	4,2%	73,3%
GB	193746	68,1%	86,2%
FR	175357	1,6%	10,4%
RU	174021	17,2%	97,5%
IT	92378	36,2%	65,4%
AU	79895	65,2%	67,3%
SE	34249	26,7%	32,0%
PL	31203	0,3%	82,8%
BR	27072	70,6%	78,7%
ES	26643	11,6%	76,8%
IN	24830	5,7%	31,4%
NL	23623	11,3%	45,1%
FI	22686	2,4%	7,5%
UA	19976	2,1%	99,0%
CA	19870	2,0%	63,7%
СН	16208	2,7%	40,0%
AT	15121	42,8%	69,7%
DK	14990	2,9%	29,5%
IL	10431	75,6%	85,8%

^{*} either no inventor or the inventor is known but missing country/missing geocoded information

4- Patent applications with legal applicants with missing country of the applicants or missing geocoded address of applicants

Table 13: Share of priority patent applications with legal applicants with information on the country of the applicant or with geocoded address of applicant according to the patent office for the 25^{th} largest patent offices

Patent office	Nber of PI patent applications	Share of PI patent applications with at least one applicant without assigned country*	Share of PI patent applications with at least one applicant without geocoded address*
Total	13333585	16,3%	30,9%
JP	4421954	1,3%	7,8%
CN	3205972	57,8%	66,3%
US	2206472	2,1%	9,0%
KR	1265278	2,9%	48,9%
DE	610583	0,1%	19,0%
EP	278071	0,1%	6,6%





TW	215233	0,6%	72,9%
GB	193746	22,3%	34,2%
FR	175357	0,1%	15,1%
RU	174021	16,7%	97,3%
IT	92378	47,3%	60,7%
AU	79895	45,5%	50,6%
SE	34249	0,1%	22,4%
PL	31203	0,1%	58,2%
BR	27072	0,1%	56,4%
ES	26643	3,5%	44,7%
IN	24830	2,6%	23,7%
NL	23623	9,7%	44,7%
FI	22686	0,1%	4,0%
UA	19976	0,1%	98,5%
CA	19870	0,5%	51,4%
СН	16208	0,8%	39,2%
AT	15121	0,4%	35,3%
DK	14990	0,4%	17,4%
IL	10431	40,5%	61,8%

^{*} either no applicant or the applicant is known but missing country/missing geocoded information

Tests of consistency

1- Priority patents

We compare the appln_id of the patent with the earliest_filing_id. For priority patent applications (characterised by appln_first_priority_year = 0, a field added by UPEM), the appln_id and the earliest_filing_id should be identical.

This is not the case for 456 387 appln_id (3,42% of the 1 313 333 585 priority patent applications).

2- Geocoding of the addresses of inventors

We compare the country of the inventors given in the RISIS patent database with the country attributed to the inventor after the geocoding step. When the 2 countries are known for a given address, in 99,77% of the case, the country is the same.

3 Technical Specifications

3.1 Information on the data base system

Current data base system used

The current data base system is My SQL 5.1.63 with MyISAM as the default storage engine. In term of maintainability and backup, the main advantage of this storage engine is to use three different files for each table of a database:





- the data file has a .MYD (MYData) extension;
- the index file has a .MYI (MYIndex) extension;
- the structure file has a .frm extension.

MySQL is optimized for an intensive usage: a high level of accessibility and efficiency, for a low amount of users

Planned future technical changes concerning data base system

None

3.2 Technical variable definition

Variables present in PATSTAT raw data are defined below.

Table 14: Name and definition of the variables already present in PATSTAT and included in RISIS Patent

Patent		
APPLN_ID	Application unique identifier	
APPLN_KIND	Kind of Application	
	A patent	
	_W PCT application (in the international phase)	
	_T used by some offices (e. g. AT, DE, DK, ES, GR, HR, PL, PT, SI, SM, TR) for applications which are "translations" of granted PCT or EP applications	
	_P provisional application (US only)	
	F design patent	
	_D2, D3 artificial	
	_Other "exotic" kind codes	
APPLN_NR	Application number	
	Number issued by the Patent Authority where the National, International or Regional application was filed	
APPLN_AUTH	Office where the patent was applied	
APPLN_ABSTRACT	Abstract of the application	
APPLN TITLE	Title of application	
APPLN ABSTRACT LG	Language of abstract of application	
APPLN TITLE LG	Language of title of application	
DOCDB_FAMILY_SIZE	Size of DOCDB simple family of a given	
	application	
DOC_STD_NAME	Standardised name as recorded in DOCDB	
	Standard name attributed to applicant and inventor names for inclusion in DOCDB. It is not 100% certain that the DOCDB standardised names are always linked with the correct person name, in particular if the person information came from a source other than DOCDB. This is especially true for names in	





AND INNOVATION POLICY STUDIES	
	USPTO patents.
	In case DOCDB does not provide a DOCDB standardized
	name, this attribute will contain the same data as the
	attribute PERSON_NAME.
DOC_STD_NAME_ID	ID for the DOCDB standardized name
EARLIEST_FILING_DATE	Date of the earliest filing
LAKEIEST_HEINO_DATE	Dute of the curies thing
	The earliest date of the filing dates of the application
	itself, its international application, its Paris Convention
	priority applications, the applications with which it is
	related via technical relations and its application
	continuations. Only directly related applications are considered; this is unlike the INPADOC family, where
	applications might also be indirectly related.
	approximation and are man confirmation.
EARLIEST_FILING_YEAR	Year of the earliest filing date
EARLIEST_PUBLN_YEAR	V () 1 1 1 1 1 1 1 1 1
	Year of the earliest publication date of an
	application
GRANTED	Granted indicator
	"1" if there exists a publication of the grant; "0" otherwise
IPC_CLASS_SYMBOL	1 if filere exists a publication of the grant, o otherwise
	IPC classification symbol (IPC 8th edition)
	Classification symbol according to the International Patent
	Classification, eights edition (entered into force January 1,
	2006)
NB_CITING_DOCDB_FAM	Number of forward citations on family level
	Number of distinct DOCDB simple families citing at least
	one of the publications or applications of the DOCDB
	simple family of the current application
PERSON_ID	Person identification
PERSON_NAME	Person name
DOM ID	ID for the PATSTAT standardized name
PSN_ID	
PSN_NAME	PATSTAT standardized name
	The attribute is populated for all persons. Names of
	persons which have not been harmonized are just copied
	from the attribute PERSON_NAME.
BSN SECTOR	Sector of the applicant
PSN_SECTOR	INDIVIDUAL . COMPANY . LINUXIONAL
	INDIVIDUAL ; COMPANY ; UNKNOWN ; GOVERNMENT ; NON-PROFIT ; UNIVERSITY ;
	HOSPITAL
	Publication Authority or Publishing office
PUBLN_AUTH	Samuel Action
	Patent Authority that issued the publication of the
	application
PUBLN_CLAIMS	
	Indicator of the number of claims in the given
1	publication





PUBLN_DATE	Publication date
	Date on which the publication was made available to the public
PUBLN_KIND	Kind of Publication
	Publication kind attributed by the Patent Authority issuing the publication
PUBLN_LG	Publication language
PUBLN_NR	Publication number
	Number given by the Patent Authority issuing the publication

Table 15: Name and definition of the variables added in RISIS Patent (non included in PATSTAT or modified)

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Thomy parem for which the invention is projected		Priority patent for which the invention is protected	





AND INNOVATION POLICY		
	at SINO (info of Inpadoc family)	
KR	Priority patent for which the invention is protected at KINO (info of Inpadoc family)	New info provided
PCT in the Inpadoc family	Priority patent for which the invention is protected using a PCT patent (info of Inpadoc family)	New info provided
Number patents in docdb family	Number patent applications in docdb family (restricted family)	New info provided
Number distinct offices in docdb family	Number of distinct patent offices where patents where applied for in docdb family (restricted family)	New info provided
Number patents in inpadoc family	Number patent applications in docdb family (extended family)	New info provided
Number distinct offices in inpadoc family	Number of distinct patent offices where patents where applied for in docdb family (extended family)	New info provided
Domain	Fractional counting of priority patent on the 5 domains	New info provided
Techno fields	Fractional counting of the priority patent on the 35 technological fields	New info provided
Techno subfields	Fractional counting of the priority patent on the 401 technological subfields	New info provided
IPC full textual description	Aggregation of the hierarchical IPC description	New info provided
IPC class 4 digits	Fractional counting of the priority patent on the 615 technological 4 digits classes	New info provided
Earliest publication of grant	First notification of a grant	Reshaped info from PATSTAT

3.3 Description of the Entity Relationship Model

The data model of the RISIS Patent database is shown below. It includes 6 tables related using the identifier of the priority patent application (appln_id):

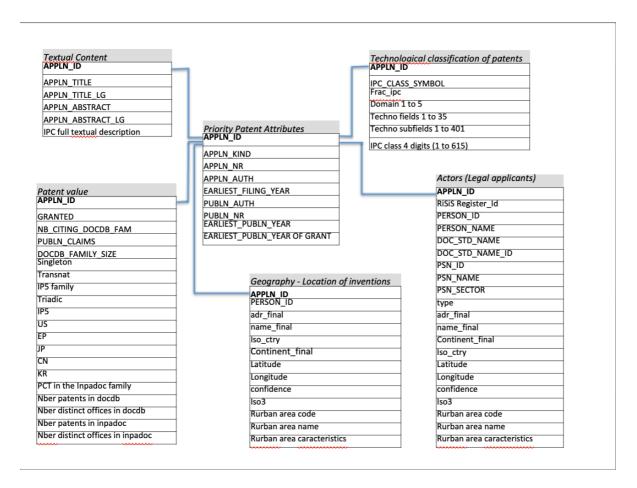
- Table Priority Patent Attributes gives a set of information related to the patent application and publication places and dates,
- Table Textual Content includes the pieces of textual information useful for text mining. It aims at defining the core of the protected inventions beside the predefined technological classifications
- Table technological classification of patents relates patent to technology on a fractional counting based using existing classification built on IPC codes
- Table Patent value proposes several indicators to estimate the patent application value
- Table Geography Location of inventions informs on the locations of the inventions based on the inventors addresses.





- Table Actors focuses on the institutions that patent and give information on their type, name and location.

Table 16: Data model of RISIS Patent



The data model of the PATSTAT2017 database in shown in Appendix 5.

3.4 Interfaces for access and to other infrastructures

RISIS Patent will be inter-linked with the RISIS organisation registers, i.e. the firm register (FirmReg), and public sector (org register id of institutions). Furthermore, the database is designed to comply with RISIS integrative dimensions, actors, space as described in the following.

Geocoding and allocation to rurban areas

Geocoding is done on inventors and applicants using the CORTEXT geocoding tools (see specific documentation on the CORTEXT Platform). It provides for each inventor and applicant it geocoordinates. The % of addresses that can be geocoded is very high (around 98%), but the issue is to have addresses, and we face here a critical issue for the PATSTAT database.

We focus here on inventor addresses, i.e. pieces of detailed geographical information enabling address geocoding (city, county, street,). There are multiple strategies by firms where to take their patents. We thus do not use the address of applicants for analysing the geography of inventions. We focus on the addresses of inventors. Their presence and quality varies depending





upon offices. For instance a study done by SPRU in the early 2000s demonstrated that the USPTO could not be trusted for addresses of inventors for patents taken elsewhere and extended to the US.

The raw coverage of addresses in PATSTAT for priority patents is limited and it has been a preoccupation by numerous teams to increase it.

We process data with the following steps to improve the address coverage:

- We first retrieve addresses that are not locate in the adequate item in PATSTAT (addresses retrieved from natural or doc standardised names)
- We incorporate external resources available: REGPAT from OECD, addresses provided for by INPI, Japanese addresses (thanks to colleagues in Japan)
- For priority patents still without addresses, we then look into the Inpadoc family to look for inventors and addresses with specific rules linked to proximity non-US patents.

The process allows to end in RISIS Patent with 75% of inventors with an address (to be compared with 10% in the initial raw PATSTAT data) and 67.4% of the addresses are geocoded. The share of geocoded addresses varies according to the countries (see table below). It exceeds 80% in most of the western countries.

Table 17: Steps for completing the addresses of inventors

Steps in filling inventor's addresses	Number of inventor's addresses	Share of inventor's addresses
PATSTAT2017 (raw data)	3,669,681	10,3%
REGPAT info	349,016	1,0%
INPI info	271,431	0,8%
JPO info	3,940,587	11,1%
Propagation of addresses within Inpadoc families	14,144,527	39,8%
Filling Artificial patent addresses	4,345,018	12,2%
Missing addresses in RISIS Patent	8,785,687	24,7%
Total	35,505,947	100,0%

Table 18: Completeness of the addresses of inventors and geocoding

Country of inventor	Raw PATSTAT data with geo info	Risis Patent with geo info	Share of addresses present in Risis Patent (more than country info)	Number of geocoded addresses in RISIS Patent	Share of geocoded addresse s in RISIS Patent
All	3,669,681	35,505,949	75,3%	23,942,110	67,4%





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JP	61,109	9,970,566	99,7%	9,310,142	93,4%
Unknown	718	6,150,087	5,9%	1,754	0,0%
CN	37,657	5,252,217	86,4%	4,237,224	80,7%
US	2,578,308	5,015,934	98,4%	4,840,760	96,5%
KR	14,155	3,093,326	77,1%	1,423,080	46,0%
DE	165,991	1,738,042	83,6%	1,387,630	79,8%
TW	122,250	728,935	72,4%	405,879	55,7%
RU	12,442	569,052	9,1%	41,581	7,3%
FR	52,261	500,759	94,9%	466,554	93,2%
CA	92,644	248,754	92,3%	209,858	84,4%
GB	50,807	235,926	82,3%	167,786	71,1%
IT	37,243	186,966	92,7%	127,946	68,4%
NL	30,187	182,245	92,9%	160,646	88,1%
IN	64,402	161,550	96,3%	137,160	84,9%
CH	41,613	146,093	90,4%	126,250	86,4%
SE	26,015	124,340	96,8%	115,794	93,1%
IL	38,094	112,700	97,4%	88,386	78,4%
ES	16,060	99,414	65,2%	54,141	54,5%
PL	15,601	97,771	29,0%	26,359	27,0%
FI	59,292	89,157	96,7%	84,030	94,2%
AU	12,781	82,815	97,8%	78,186	94,4%
UA	658	76,519	5,6%	2538	3,3%
DK	11,230	69,667	96,0%	57413	82,4%
BE	20,331	68,511	93,9%	60060	87,7%
AT	12,921	67,387	82,3%	53035	78,7%

Actors

We deal with actors that are legal applicants (individual applicants were discarded from the database in RISIS Patent. In the current RISIS Patent database, we only rely on the sectorial information provided in the raw PATSTAT database 10.

Integration with RCF

The current RISIS Patent is made available for access to researchers in RISIS is foreseen to be fully incorporated in RCF, under the condition of controlled access and that security of usage is given (i.e. access for selected users with a concrete research project to the parts of the dataset needed for the research). Linking to other datasets in the RCF will be realized via the RISIS registers (providing the respective identifiers to the registers in RISIS Patent). Technical issues for

¹⁰ Harmonizing names and allocation of assignee sectors in Patstat raw data was done by ECOOM (K.U. LEUVEN; http://www.ecoom.be/en/EEE-PPAT).





incorporation of RISIS Patent into RCF (e.g. database system, how can a user access which parts of the dataset, etc.) are to be defined in close cooperation with WP4 beginning with autumn.

4 Scientific use and main references

RISIS Patent is an accessible and rich data source via RISIS for research activities in the production of knowledge using patent data. It allows studying the dynamics of knowledge creation along different dimensions: space, actors and technologies.

Thanks to its links with other RISIS facilities, Risis Patent enables to access to these dimensions at a coarse level or at a fine grained level using either usual classification (for technologies, geography) or designing ad-hoc data subsets of patents in specific topics of inventions, for a particular type of institutions in given geographical spaces.

It had been recently used to:

.Observe the distribution and location of the inventive activities of a group of European public research centres in the field of marine biotechnology (the EMBRIC project)

Explore the Inventive Productivity of Multinational Firms using non parametric modelling (Conditional Efficiency Analysis)

.Analyse of **the internationalisation of applied knowledge** production with a focus on special countries (Israel, central European countries)

Recent References

Laurens, P., Le Bas, C., Schoen, A. (2018), Worldwide IP coverage of patented inventions in largepharmafirms: to what extent do the internationalisation of R&D and firm strategy matter? Submitted to the International Journal of Technology Management

Laurens, P., Le Bas, C., Lhuillery S., Schoen, A., (2018) Firm specialisation in clean energy technologies: the influence of path dependence and technological diversification. Revue dăconomie Industrielle, n°164 (4eme trimestre 2018)

"Evolving technological capabilities of firms; Complexity, divergence, and stagnation" Antoine Schoen²Patricia Laurens¹, Alfredo Yegros³, Philippe Larйdo^{4,5} STI conference Paris September, 2017

Gaston Heimeriks, Antoine Schoen, Patricia Laurens, Alfredo Yegros and Dieter Franz Kogler Knowledge, networks and proximities - An analysis of knowledge dynamics in the Chemical and Pharmaceutical and Biotechnology sectors
Eu-spri 2018 conference Paris 2018

Laurens Patricia, Antoine Schoen, Pierluigi Toma and Cinzia Daraio Exploring the Innovative Efficiency of Big Multinational Firms through Conditional Efficiency Analysis

STI 2018, Leiden (Netherlands) 12-14 September





































Appendix







Appendix 1: Artificial patents

The very first filing of a patent application that aims at protecting a novel invention, also known as a priority patent, is considered as a promising type of document for analysing the dynamics of knowledge creation in the field of technology (de Rassenfosse et al., 2013).

If most of the worldwide priority patent applications included in the PATSTAT database are the published patents, there is an additional group of patents, classified as «artificial patents that are not part of the EPO database. The artificial priority patents are priority patents cited in further patent extensions included in the PATSTAT database but for these patents the application was not identified with 100% certainty by EPO.

An artificial priority patent in its original state contains very scarce information. The only information included in the Patent database provided by EPO for these documents relates to the patent office where the artificial priority patent has been applied for, the date and the type of the application and whether the patent has been cited as a priority patent or through another type of citation. All the other information, which is usually included in fully documented patent documents, is missing: the technology domains, the inventors and applicants addresses and names, the title and the abstract of the patent application.

In RISIS Patent, we fill both the applicants and the inventors names and addresses but also of IPC codes in the artificial priority patents based on the identification and use of this piece of information retrieved from a non artificial patent belonging to the same INPADOC family. To select the candidate from which information is retrieved, a set of sequential rules is defined in order to select a candidate patent as close as possible to the artificial one. The criteria relate to the type of information available in the candidate patent, the nature of the priority link between the artificial patent and the selected candidate patent, the time lag between the two applications and the patent offices. In order to be considered as a potential candidate, the patent must contain information concerning addresses, either the inventors addresses or the applicants addresses or both. A candidate with a direct priority link with the artificial patents is selected first (from table tls204 of the PATSTAT database). In absence of such a link, a candidate with a direct continuity link is selected (continuation, division/continuation in parts/internal continuities in table tls 216). At last, candidate patents with indirect links are selected. Besides the type of links, we also consider the time lag between the artificial and the candidate patents. For two candidates with the same link, we select the candidate with a date of filing closest to the filing date of the artificial patent (the maximum authorised time lag is fixed to five years). Finally, we give a higher priority to US candidates to fill US artificial patents. For non US artificial patent applications, candidates filed as PCT, or EP, JP, FR, DE received the highest priority. A schematic view of the rules of selection of candidates chosen for replenishing artificial patents is presented in figure A1.

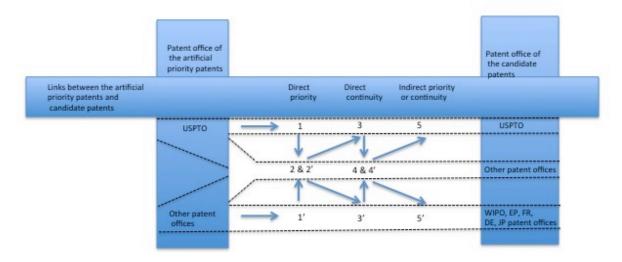
As soon as a candidate patent is selected, its information related to the names and addresses and the IPC codes is used to fill the artificial patent. This procedure made possible to propagate information from a candidate patent in 99.3% of the artificial priority patents filed between 1995 and 2010

These high retrieval percentages show that the filling step of artificial patents was very effective. It thus provides a better coverage of the overall inventive activities when using the priority patents, in particular in patent offices where the share of artificial patents is high (EPO, USPTO patent offices in India or Australia).

Figure A1: Schematic description of the different steps to fill inventors and applicants addresses in artificial priority patents.







Scripts are shown in https://github.com/cortext/PATSTAT/blob/master/artificial/README.md

Reference:

de Rassenfosse, G., Dernis, H., Guellec, D., Picci, L., van Pottelsberghe de la Potterie, B. (2013). The worldwide count of priority patents: a new indicator of inventive activity. Research Policy 42, 720-737.





Appendix 2: Type of applicants

One of the main goals in our research activities is the study and analysis on the dynamics of R&D and innovations made by legal entities, such as corporations, universities, research centers and in general every class of entity that do not fit into the categorization of natural person. Considering the above, we have worked with the data contributed by PATSTAT to start with the data restructuring in order to begin on the classification process, in this way we have defined two entities classes: legal and person. A third one unknown contains the cases where it was not possible to allocate a type to the applicant.

In the entities that can be found within the PATSTAT applicants coexist a large proportion of homonym names, for instance, the word 'Ford' may be tagged as a company or as an individual, which means that, using a direct approach of detection where several functions that implement gazetteers and by combing regular expressions, could lead in a low quality results for the categorization of legal entities and individuals. Another ambiguity that we had to face to was for companies names that do not have any corporate ending and consequently is not likely that we are able to label those entities with just a dictionary list of legal suffix.

Therefore, we turn the approach of the solution, instead of merely doing a direct match of terms we used an heuristic approach in the patent context in order to separate the different entities into three subsets named as 'probably legal', 'probably individual' and 'ambiguous'. The allocation of each entity is designated by a series of methods and rules that are relay on not only on the used of gaztteers but on the characterization of the applicants through the relation with the patent, besides some simple lexical identifiers. Details of the methodology are described in:

https://github.com/cortext/PATSTAT/tree/master/Actors

Results are shown below. Almost 1/3 applicants are persons. They are present in 23% of the patents applications either alone (15% of the applications) or as co-applicant of legal entities (8%).

Table A2-1: Distribution of applicants according to the type of applicants

Type of applicants	Number of applicants	Share of applicants
Undefined	166,834	0,8%
Legal	14,355,395	67,8%
Person	6,646,629	31,4%
Total	21,168,858	100,0%

Table A2-2: Distribution of type of applicants in priority patent applications

Type of applicant	Number of patents including the type of applicants	Share of patents including the type of applicants
Undefined	154,161	1,0%
Legal	13,333,585	84,3%





Person	3,625,856	22,9%
Total patents	15,824,851	100%





Appendix 3: Classification of patent technologies

Table A-3: Definition of the Domains, fields and subfields classification

Label domaines	field s	Label fields	sfiel ds	Label subfields	ipc	not_ ipc	not_ appln id
		Electrical					
		machinery,					
Electrical		apparatus,	TO1F				
engineering	TF01	energy	01	Lighting	F21		
		Electrical					
		machinery,					
Electrical		apparatus,	T02F	Cables with Special Electric			
engineering	TF01	energy	01	Properties	H01B		
		Electrical					
		machinery,					
Electrical		apparatus,	T03F				
engineering	TF01	energy	01	Resistors	H01C		
		Electrical					
		machinery,					
Electrical		apparatus,	TO4F				
engineering	TF01	energy	01	Magnets	H01F		
		Electrical					
_		machinery,					
Electrical		apparatus,	T05F		_		
engineering	TF01	energy	01	Capacitors	H01G		
		Electrical					
		machinery,					
Electrical		apparatus,	T06F				
engineering	TF01	energy	01	Electric Switches	H01H		
		Electrical					
		machinery,					
Electrical		apparatus,	T07F				
engineering	TF01	energy	01	Discharge Lamps	H01J		
		Electrical					
Floridad		machinery,	T00F				
Electrical	TEO1	apparatus,	T08F	Florida Israella accident	11011/		
engineering	TF01	energy	01	Electric Incandescent Lamps	H01K		
		Electrical					
Electrical		machinery,	T09F				
	TEO 1	apparatus,	01	Pattorios and related	HO144		
engineering	TF01	energy	UI	Batteries and related	H01M		-
		Electrical machinery,					
Electrical		apparatus,	TIOF	Electrically-Conductive			
engineering	TF01	energy	01	Connections	H01R		
engineering	1101	Electrical	01	Connections	TIVIK		<u> </u>
		machinery,					
Electrical		apparatus,	TIIF				
engineering	TF01	energy	01	Spark Gaps	H01T		
o.igiilociilig	1.101	Electrical		Chark Cabs			
		machinery,					
Electrical		apparatus,	T12F	Boards For The Distribution Of			
engineering	TF01	energy	01	Electricity	H02		
ყ	1	Electrical	+				
		machinery,					
Flectrical			T13F				
Electrical engineering	TF01	apparatus, energy	T13F 01	Electric Heating	H05B		





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engineering		machinery,	01	human beings		
		apparatus,				
		energy				
		Electrical				
		machinery,				
Electrical		apparatus,	T15F			
engineering	TF01	energy	01	Static Electricity	H05F	
		Electrical				
		machinery,				
Electrical		apparatus,	T16F			
engineering	TF01	energy	01	Other subjects electricity	H99Z	
Electrical		Audio-visual	TO1F			
engineering	TF02	technology	02	Displaying Advertising	G09F	
Electrical		Audio-visual	T02F	1 / 3		
engineering	TF02	technology	02	Arrangements For Control	G09G	
Electrical		Audio-visual	T03F	Information Storage Based		
engineering	TF02	technology	02	Record Carrier	G11B	
Electrical		Audio-visual	T04F		H04N	
engineering	TF02	technology	02	Scanning details of television	3	
Electrical	02	Audio-visual	T05F	Counting dorans of followishor	H04N	
engineering	TF02	technology	02	Details of television systems	5	
Electrical	1102	Telecommunicati	T06F	Dorum of relevision systems	H04N	
	TF02		02	Television systems	7 TO 4 N	
engineering Electrical	1102	ons Audio-visual	T07F		•	
	TEOO					
engineering	TF02	O,	02	systems	9 H04N	
Electrical	тгоо	Telecommunicati	T08F			
engineering	TF02	ons	02	Colour television systems	11	
Electrical .	тгоо	Audio-visual	T09F		H04N	
engineering	TF02	technology	02	Stereoscopic television systems	13	
Electrical		Audio-visual	T10F	Stereoscopic colour television	H04N	
engineering	TF02	technology	02	systems	15	
Electrical		Audio-visual	TIIF	Diagnosis for television	H04N	
engineering	TF02	technology	02	systems	17	
Electrical		Audio-visual	T12F		H04N	
engineering	TF02	technology	02	Pictorial Communication	101	
Electrical		Audio-visual	T13F			
engineering	TF02	technology	02	Loudspeakers Microphones	H04R	
Electrical		Audio-visual	T14F			
engineering	TF02	technology	02	Stereophonic Systems	H04S	
Electrical		Audio-visual	T15F			
engineering	TF02	technology	02	Printed Circuits	H05K	
Electrical		Telecommunicati	TO1F			
engineering	TF03	ons	03	Transmission Systems	G08C	
Electrical		Telecommunicati	T02F			
engineering	TF03	ons	03	Waveguides	H01P	
Electrical		Telecommunicati	T03F			
engineering	TF03	ons	03	Aerials	H01Q	
Electrical	1	Telecommunicati	TO4F			
engineering	TF03	ons	03	Transmission	HO4B	
Electrical		Telecommunicati	T05F			
engineering	TF03	ons	03	Broadcas Communication	H04H	
Electrical		Telecommunicati	T06F		-	
engineering	TF03	ons	03	Multiplex Communication	H04J	
Electrical	15	Telecommunicati	T07F			
engineering	TF03	ons	03	Secret Communication	H04K	
Electrical	155	Telecommunicati	T08F	Court Commonication	7.10 TIX	
engineering	TF03	ons	03	Telephonic Communication	H04M	
Electrical	1103	Telecommunicati	T09F	Transmission or reproduction	H04N	
engineering	TF03	ons	03	of documents	1	
					•	
Electrical	TF03	Telecommunicati	T10F	Selecting (Switches/Relays)	H04Q	





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engineering		ons	03				
Electrical		Digital	TO1F	Transmission Of Digital			
engineering	TFO4		04	Information	H04L		
Electrical		Digital	T02F		H04N		
engineering	TFO4	•	04	Selective content distribution	21		
Electrical		Digital	T03F				
engineering	TFO4	•	04	Wireless Communication	H04W		
gg		Basic	-	, , , , , , , , , , , , , , , , , , ,			
Electrical		communication	TO1F				
engineering	TF05	processes	05	Basic Electronic Circuitry	H03		
Electrical	1103	Computer	TO1F	Mechanically computed Digital	1103	G06	
engineering	TF06	•	06	Computers	G06	Q	
Electrical	1100	Computer	T02F	Componers	000	Q	
engineering	TF06	•	06	Speech Anal Or Synth	G10L		
Electrical	1100		T03F	Speech Anal. Or Synth.	GIUL		
	TEO 4	Computer		Cint's Cinne	C11C		
engineering	TF06	0,	06	Static Stores	G11C		
Electrical	TE0.7	IT methods for	T01F		60/0		
engineering	TF07	management	07	Data Processing Systems	G06Q	<u> </u>	
Electrical	TE0 0		TO1F				
engineering	TF08	Semiconductors	08	Semiconductor Devices	H01L	ļ	
		•	TO1F				
Instruments	TF09	Optics	09	Optical Elements Systems	G02		
	l_		T02F				
Instruments	TF09	Optics	09	Photograph Apparatus	G03B		
			T03F				
Instruments	TF09	Optics	09	Photographic Processes	G03C		
				Apparatus For Processing			
			TO4F	Exposed Photographic			
Instruments	TF09	Optics	09	Materials	G03D		
			T05F				
Instruments	TF09	Optics	09	Photomechanics of Surfaces	G03F		
		-	T06F	Photomechanical Production Of			
Instruments	TF09	Optics	09	Surfaces	G03G		
		•	T07F				
Instruments	TF09	Optics	09	Holography	G03H		
		•	T08F				
Instruments	TF09	Optics	09	Emission	H01S		
		'	T01F				
Instruments	TF10	Measurement	10	Measuring Length Thickness	G01B		
	T		T02F				
Instruments	TF10	Measurement	10	Measuring Distances Levels	G01C		
	1		T03F	<u></u>	23.3		
Instruments	TF10	Measurement	1001	Multivariable Measuring	G01D		
	1		T04F	The second of th			
Instruments	TF10	Measurement	1041	Measuring Volume Flow	G01F		
	1		T05F				
Instruments	TF10	Measurement	1031	Weighing	G01G		
11311 011161113	1110	Medaulellell	T06F	Troigining	3010	 	
Instruments	TF10	Measurement	1007	Measuring Vibrations	G01H		
111311 011161113	1110	Mensorement	T07F	Medsoring vibrations	50111	-	
Instruments	TF10	Measurement	1077	Optical Measurements	G01J		
111311 011161113	1110	Mensorement	T08F	Oplical Measuremeths	2013	-	
In a truma a rata	TEIO	AA o maumo ma a mat	108F	Magazina Tamparatura	G01K		
Instruments	TF10	Measurement	T09F	Measuring Temperature	GUIK	-	
In a try a t -	TEIO	Ma maumama s == ±			COL		
Instruments	TF10	Measurement	10	Torque Work	G01L	<u> </u>	
la alarres - 1	TEIA	AA = =================================	T10F	Tanking Characters	C0114		
Instruments	TF10	Measurement	10	Testing Structures	G01M	C 0.1	
			Tilei			G01	
 	TEIO	AA = =================================	T11F1	Chamiani Bhuaisai Araalusa	COIN	N	
Instruments	TF10	Measurement	0	Chemical Physical Analyses	G01N	33	





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Instruments	TF10	Measurement	T12F 10	Measuring Speed Acceleration	G01P
			T13F		
Instruments	TF10	Measurement	10	Scanning-Probe Techniques	G01Q
Instruments	TF10	Measurement	T14F 10	Measuring Electric Variables	G01R
man omema	1110	Medsorement	T15F	Medsoring Electric variables	COIK
Instruments	TF10	Measurement	10	Radio Direction-Finding	G01S
			T16F	y	
Instruments	TF10	Measurement	10	Geophysics	G01V
_			T17F		
Instruments	TF10	Measurement	10	Meteorology	G01W
la starran a a ta	TF10	M = ==================================	T18F 10	Hanalan.	G04
Instruments	IFIU	Measurement	T19F	Horology	G04
Instruments	TF10	Measurement	10	Details Of Instruments	G12B
mon omems	11.10	Wedsor emem	T20F	Details of hisherins	0125
Instruments	TF10	Measurement	10	Other subjects nucleonics	G99Z
		Analysis of			
		biological	TO1F	Material Analysis by	G01N
Instruments	TF11	materials	11	Chem/Phys Properties	33
_			TO1F		
Instruments	TF12	Control	12	Control Systems in General	G05B
1	TELO		T02F		COED
Instruments	TF12	Control	12 T03F	Variables	G05D
Instruments	TF12	Control	12	Regulating Electric Variables	G05F
man omema	1112	Cominor	T04F	Regulating Electric Variables	0031
Instruments	TF12	Control	12	Checking Devices	G07
			T05F		
Instruments	TF12	Control	12	Signalling Systems	G08B
			T06F		
Instruments	TF12	Control	12	Traffic Control Systems	G08G
	TE10		T07F		COOR
Instruments	TF12	Control	12 T08F	Appliances	G09B
Instruments	TF12	Control	12	Ciphering Apparatus	G09C
mish officins	1112	Cominor	T09F		0070
Instruments	TF12	Control	12	Tables	G09D
		Medical	TO1F		
Instruments	TF13	technology	13	Surgery-Diagnosis	A61B
		Medical	T02F		
Instruments	TF13	technology	13	Dentistry	A61C
	TE1 ^	Medical	T03F	V. I. C.	
Instruments	TF13	technology	13 T04F	Veterinary	A61D
Instruments	TF13	Medical technology	1045	Blood Vessel Filters	A61F
mish unlettis	1113	Medical	T05F	DIOOU YESSEI IIIIEIS	AUII
Instruments	TF13	technology	13	Furniture for Patients	A61G
		Medical	T06F		-
Instruments	TF13	technology	13	Therapy Apparatus	A61H
		Medical	T07F		
Instruments	TF13	technology	13	Medical Containers	A61J
	TE1 ^	Medical	T08F	M	
Instruments	TF13	technology	13	Methods For Sterilising	A61L
Instruments	TF13	Medical technology	T09F 13	Devices for Introducing Media in Body	A61M
mish uniems	1113	Medical	T10F	in body	VO IM
Instruments	TF13	technology	13	Electrotherapy	A61N
Instruments	TF13	Medical	T11F1	X-Ray Technique	H05G
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		technology	3				
		Organic fine	TO1F		A61K		
Chemistry	TF14	chemistry	14	Cosmetic Preparations	8		
		Organic fine	TO2F				
Chemistry	TF14	chemistry	14	Use of Cosmetics	A61Q		
-		Organic fine	TO3F				
Chemistry	TF14	chemistry	14	Organic Chemistry	C07B		A61K
,		Organic fine	TO4F				
Chemistry	TF14	chemistry	14	Compounds	C07C		A61K
,		Organic fine	T05F	1			7.0
Chemistry	TF14	chemistry	14	Heterocyclic Compounds	C07D		A61K
Gironnion	+	CHOTHISTIY		Compounds with Elts Other	007.5		AUIK
		Organic fine	T06F				
Chemistry	TF14	chemistry	14	Se or Te	C07F		A 4 11/
Chemisiry	1114	Organic fine	T07F	36 01 16	C0/1		A61K
Chemistry	TF14	chemistry	14	Sugars Nucleotides	C07H		
Chemistry	11/14			Sugars Nucleonaes	СО/П		A61K
CI	TE1.4	Organic fine	T08F	c	6071		
Chemistry	TF14	chemistry	14	Steroids	C07J		A61K
		Organic fine	T09F		0.455		
Chemistry	TF14	chemistry	14	Combinatorial Chemistry	C40B	ļ	A61K
			TO1F	Compounds Of Unknown			
Chemistry	TF15	Biotechnology	15	Constitution	C07G		A61K
			TO2F				
Chemistry	TF15	Biotechnology	15	Peptides	C07K		A61K
			TO3F	Apparatus For Enzymology Or			
Chemistry	TF15	Biotechnology	15	Microbiology	C12M		A61K
,		37	TO4F				
Chemistry	TF15	Biotechnology	15	Culture Media	C12N		A61K
			T05F		0.2.		AUIK
Chemistry	TF15	Biotechnology	15	Processes	C12P		A61K
Chemistry	1113	Biorecimology	T06F		CIZI		AOIK
Chamaiatan	TF15	Diata dan alamu	15		C12Q		
Chemistry	ILIO	Biotechnology	T07F	Enzymes Or Micro-Organisms	CIZQ		A61K
Cl		Distantantan		Minn On	CIOD		
Chemistry		Biotechnology	15	Micro-Organisms-General	C12R		A61K
			T08F				
Chemistry	TF15	Biotechnology	15	materials	C12S		A61K
			TO1F			A 4 11/	
Chemistry	TF16	Pharmaceuticals	16	Medical Preparations	A61K	A61K 8	
,			TO2F				
Chemistry	TF16	Pharmaceuticals	16	Chemical Compounds	A61P		
,	† · · ·	Macromolecular		2.2 2 2.2 2			
		chemistry,	TO1F				
Chemistry	TF17	polymers	17	Polysaccharides	C08B		
2.10/111011 y	1/	Macromolecular	• •	,		1	
		chemistry,	T02F				
Chemistry	TF17	polymers	17	Treatment Of Rubbers	C08C		
CHEITHSILY	1117	Macromolecular	17	Hedillelli Ol Kubbels	2000	-	
			TOOF	Administration of the Color			
Chart	TETT	chemistry,	T03F		COOF		
Chemistry	TF17	polymers	17	Unsaturated Bonds	C08F	ļ	
		Macromolecular	- :-				
		chemistry,	TO4F				
Chemistry	TF17	polymers	17	Unsaturated Bonds	C08G	<u> </u>	<u> </u>
		Macromolecular					
		chemistry,	T05F				
Chemistry	TF17	polymers	17	Macromolecules	C08H		
		Macromolecular					
		chemistry,	TO6F	Inorg Or Non-Macromolr			
Chemistry	TF17	polymers	17	Organ Subst	C08K		
Chemistry	TF17	Macromolecular	T07F		C08L		
3.101111311 y	1/	, maci omolecular	10/1	Compositions Of		I	ı





AND INNOVA	TION POLI				<u> </u>
		chemistry,	17	Macromolecular Compounds	
		polymers			
			TO1F		
Chemistry	TF18	Food chemistry	18	New Plants	A01H
GI	TE10		T02F		
Chemistry	TF18	Food chemistry	18	Treatment of Dough	A21D
GI	TE10		T03F		
Chemistry	TF18	Food chemistry	18	Preseving food	A23B
CI	TE10		T04F	D . B	4000
Chemistry	TF18	Food chemistry	18	Dairy Products	A23C
CI	TE10		T05F	F 1911 - O.1	4 0 0 D
Chemistry	TF18	Food chemistry	18	Edible Oils	A23D
Character 1	TE10	F. Laboration	T06F	C (C I T	A 0.0F
Chemistry	TF18	Food chemistry	18	Coffee and Tea	A23F
CI	TE10		T07F		
Chemistry	TF18	Food chemistry	18	Chocolate	A23G
Character 1	TE10	F. Laboration	T08F	De total for Elli	A 00 I
Chemistry	TF18	Food chemistry	18	Proteins for Food	A23J
Charaister	TELO	Food chamitan	T09F	Foddor	A 22K
Chemistry	TF18	Food chemistry	18 T10F	Fodder	A23K
Chamiatry	TF18	Food shomistry	110F 18	Other Foods	A23L
Chemistry	1110	Food chemistry	T11F1	Officer roods	AZSL
Chamiatry	TF18	Food shomistry	8	Brewing Of Beer	C12C
Chemistry	1110	Food chemistry	T12F	Brewling Of Beer	CIZC
Chemistry	TF18	Food chemistry	112F 18	Fermented Solutions	C12F
Chemishy	1110	1000 Chemishy	T13F	Termemed Solutions	CIZI
Chemistry	TF18	Food chemistry	18	Alcoholic Beverages	C12G
Citetilisity	1110	1000 Chemishy	T14F	Treatment of Alcoholic	CIZO
Chemistry	TF18	Food chemistry	18	Beverages	C12H
Chemistry	1110	Tood chemishy	T15F	beverages	CIZII
Chemistry	TF18	Food chemistry	18	Vinegar	C12J
Chemishy	1110	Tood chemishy	T16F	· · · · · · · · · · · · · · · · · · ·	C13B
Chemistry	TF18	Food chemistry	18	Production of sugar juices	10
Citorinorry	1110	rood enominary	T17F	Trodoction of bogal pices	C13B
Chemistry	TF18	Food chemistry	18	Purification of sugar juices	20
,	1110	i sou enomeny	T18F		C13B
Chemistry	TF18	Food chemistry	18	Crystallisation of sugar	30
,		,	T19F		C13B
Chemistry	TF18	Food chemistry	18	molasses	35
,		,	T20F		C13B
Chemistry	TF18	Food chemistry	18	Drying sugar	40
,		,	T21F	, , ,	C13B
Chemistry	TF18	Food chemistry	18	Working-up of sugar	50
,		•		Subject matter not provided	
			T22F		C13B
Chemistry	TF18	Food chemistry	18	subclass	99
			T23F		
Chemistry	TF18	Food chemistry	18	Sugar Juices	C13D
			T24F		
Chemistry	TF18	Food chemistry	18	Sugar	C13F
			T25F		
Chemistry	TF18	Food chemistry	18	Extraction Of Sugar	C13J
			T26F		
Chemistry	TF18	Food chemistry	18	Synthesis Of Sugars	C13K
		Basic materials	TO1F	_	
Chemistry	TF19	chemistry	19	Disinfectants	A01N
	1_	Basic materials	T02F		
Chemistry	TF19	chemistry	19	Repellants	A01P
Chemistry	TF19	Basic materials	T03F	Fertilisers	C05
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chemistry 19 Basic materials T04F chemistry 19 Explosives Chemistry TF19 chemistry 19 Organic Dyes Chemistry TF19 chemistry 19 Dyeing Of Inorganics Basic materials T06F Chemistry 19 Dyeing Of Inorganics Basic materials T07F Chemistry TF19 chemistry 19 paints and inks Basic materials T08F Chemistry TF19 chemistry 19 Natural Resins	C06 C09B
Chemistry TF19 chemistry 19 Explosives Basic materials T05F Chemistry 19 Organic Dyes Basic materials T06F Chemistry 19 Dyeing Of Inorganics Basic materials T07F Chemistry TF19 chemistry 19 paints and inks Basic materials T08F	С09В
Chemistry TF19 chemistry 19 Organic Dyes Basic materials T05F Chemistry 19 Organic Dyes Chemistry 19 Dyeing Of Inorganics Basic materials T07F Chemistry TF19 chemistry 19 paints and inks Basic materials T08F	С09В
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Chemistry TF19 chemistry 19 Organic Dyes Basic materials T06F Chemistry 19 Dyeing Of Inorganics Basic materials T07F Chemistry 19 paints and inks Basic materials T08F	
Chemistry TF19 chemistry 19 Dyeing Of Inorganics Basic materials T06F 19 Dyeing Of Inorganics Basic materials T07F Chemistry 19 paints and inks Basic materials T08F	
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Chemistry TF19 chemistry 19 paints and inks Basic materials T07F 19 paints and inks Basic materials T08F	
Chemistry TF19 chemistry 19 paints and inks Basic materials T08F	10070
Basic materials TO8F	C09D
	6075
	C09F
Basic materials TO9F	6071
Chemistry TF19 chemistry 19 Polishing Compositions	C09G
Basic materials T10F	6076
Chemistry TF19 chemistry 19 Glue Or Gelatine	С09Н
Basic materials T11F1	C0911
	C09J
Chemistry TF19 chemistry 19 Applications	C09K
Basic materials T13F Production Of Gas Coke	
Chemistry TF19 chemistry 19 by distillation	C10B
Basic materials T14F	
Chemistry TF19 chemistry 19 Working-Up Tar	C10C
Basic materials T15F	
Chemistry TF19 chemistry 19 Working-Up Of Peat	C10F
Basic materials T16F	
Chemistry TF19 chemistry 19 Cracking Hydrocarbon Oi	ils C10G
Basic materials T17F	
Chemistry TF19 chemistry 19 Wet Production Of Acetyle	ene C10H
Basic materials T18F Production Of Gas From	Solid
Chemistry TF19 chemistry 19 C-Material	C10J
Basic materials T19F Modifying Combustible	Gases
Chemistry TF19 chemistry 19 Containing CO	C10K
Basic materials T20F	
Chemistry TF19 chemistry 19 Fuels	C10L
Basic materials T21F	
Chemistry TF19 chemistry 19 Lubrifiant	C10M
Basic materials T22F	
Chemistry TF19 chemistry 19 Lubrifiant indexed	C10N
Basic materials T23F	
Chemistry TF19 chemistry 19 Fats	C11B
Basic materials T24F	
Chemistry TF19 chemistry 19 Fatty Acids	C11C
Basic materials T25F	
Chemistry TF19 chemistry 19 Detergent Compositions	C11D
Basic materials T26F	10
Chemistry TF19 chemistry 19 Other subjects Chemistry	C99Z
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Chemistry TF20 metallurgy 20 Metallurgy	B22
Materials, T02F	522
	C01
Chemistry TF20 metallurgy 20 Inorganic Chemistry Materials, T03F	
· · · · · · · · · · · · · · · · · · ·	C03C
, 5,	C03C
Materials, TO4F	
Chemistry TF20 metallurgy 20 Refractories	C04
Materials, T05F	
Chemistry TF20 metallurgy 20 Metallurgy of Iron	C21
Materials, TO6F	
Chemistry TF20 metallurgy 20 Metallurgy	C22
Chemistry TF21 Surface T01F Apparatus For Applying L	iquids B05C





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		technology,	21				
		coating					
		Surface					
		technology,	T02F				
Chemistry	TF21	coating	21	Liquid Application Processes	B05D		
,		Surface					
		technology,	T03F				
Chemistry	TF21	coating	21	Layered Products	B32		
Gironnion		Surface		Layerea reaccis	502		
		technology,	TO4F				
Chemistry	TF21	coating	21	Coating Metallic Material	C23		
Chemisiry	1121	Surface	<u> </u>	Country Meranic Material	C23		
		technology,	T05F	Electrolytic Or Electrophoretic			
Chemistry	TF21	coating	21	Processes	C25		
Chemistry	11 21	Surface	21	Trocesses	CZS		
			T06F				
Cl: - 4	TEO1	technology,		Countril Countril	C30		
Chemistry	TF21	coating	21	Crystal Growth	C30		
		Micro-structural	T0.15				
a		and nano-	TO1F				
Chemistry	TF22	5	22	Micro-Structural Technology	B81		
		Micro-structural					
		and nano-	T02F				
Chemistry	TF22	O,	22	Nano-Technology	B82		
		Chemical	TO1F				
Chemistry	TF23	•	23	Boiling	BO1B		
		Chemical	T02F				
Chemistry	TF23	engineering	23	Separation	B01D		
				Evaporating and extraction			
		Chemical	T03F	and separetion and			
Chemistry	TF23	engineering	23	degaseification	B01D 1		
		Chemical	TO4F		B01D		
Chemistry	TF23	engineering	23	Separation and Filters	2		
		Chemical	T05F		B01D		
Chemistry	TF23	engineering	23	Distillation	3		
,		Chemical	T06F		B01D		
Chemistry	TF23	engineering	23	Regeneration of Filters	41		
,		Chemical	T07F		B01D		
Chemistry	TF23		23	Separating Liquids and Solids	43		
		Chemical	T08F	J 1	B01D		
Chemistry	TF23	engineering	23	Other Separation	57		
Gironnion	120	Chemical	T09F	Ciner Copulation	B01D		
Chemistry	TF23	engineering	23	Separation of isotopes	59		
Chemistry	11 23	Chemical	T10F	Separation apparatus and	B01D		
Chemistry	TF23	engineering	23	processes	6		
Chemisii y	1123	Chemical	711F	Semi-permeable membranes	B01D	 	
Chamiatry	TF23		23		7		
Chemistry	IFZ3	engineering		for separation	/		
Cl : .	TEOO	Chemical	T12F		DO1E		
Chemistry	TF23	engineering	23	Mixing	B01F		
Ch	TEGO	Chemical	T13F	Character B	DO11		
Chemistry	TF23	engineering	23	Chem and Phys Processes	B01J	<u> </u>	
a		Chemical	T14F				
Chemistry	TF23	engineering	23	Chem Or Phys Lab Apparatus	B01L		
		Chemical	T15F				
Chemistry	TF23	engineering	23	Crushing and Milling	B02C		
		Chemical	T16F				
Chemistry	TF23	engineering	23	Separation of solid materials	B03	<u> </u>	
		Chemical	T17F				
Chemistry	TF23	engineering	23	Centrifuges	B04		
ŕ		Chemical	T18F				
Chemistry	TF23		23	Spraying	B05B		
				. , ,			





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		Chemical	T19F	Generating Mechanical	
Chemistry	TF23	engineering	23	Vibrations	B06B
		Chemical	T20F		
Chemistry	TF23	engineering	23	Separating Solids and Sorting	B07
		Chemical	T21F		
Chemistry	TF23	engineering	23	Cleaning	B08
		Chemical	T22F	Chemical Processing Of Skins	
Chemistry	TF23	engineering	23	Hides Or Leather	C14C
,		Chemical	T23F		
Chemistry	TF23	engineering	23	Treating Textile	D06B
,		Chemical	T24F		
Chemistry	TF23	engineering	23	Or Stretching Textile	D06C
,		Chemical	T25F		
Chemistry	TF23	engineering	23	Bleaching	D06L
Gironnian	11.20	Chemical	T26F		2002
Chemistry	TF23	engineering	23	Phase transformation Of Gases	F25J
Chemishy	1120	Chemical	T27F	Thuse in unstermation of cuses	1233
Chemistry	TF23	engineering	23	Drying	F26
Chemisiry	1123	Chemical	T28F	Drying	120
Chamiatry	TF23		23	Places Tochnique	Н05Н
Chemistry	IFZ3	engineering Environmental	T01F	Plasma Technique	поэп
Characiatan	TEO 4			Eng Enlation	A 42C
Chemistry	IFZ4	technology	24	Fire-Fighting	A62C
a	,	Environmental	TO2F		B01D
Chemistry	TF24	0,	24	Separating Gases	45
_,		Environmental	T03F		B01D
Chemistry	TF24	0,	24	Filtering Gases	46
		Environmental	TO4F		B01D
Chemistry	TF24	technology	24	Separating by Liquids	47
		Environmental	T05F		B01D
Chemistry	TF24	technology	24	Other Separating	49
		Environmental	T06F		B01D
Chemistry	TF24	technology	24	Separating Combination	50
		Environmental	T07F		B01D
Chemistry	TF24	technology	24	Pretreatment of gases	51
		Environmental	T08F		B01D
Chemistry	TF24	technology	24	Treatment of gases	52
,		Environmental	T09F		B01D
Chemistry	TF24	technology	24	Separation of gases	53
,		Environmental	T10F	Solid Waste and Contaminated	
Chemistry	TF24		24	Soils	B09
22	1	Environmental	T11F	1 = - ···•	
Chemistry	TF24		24	Gathering of Domestic Refuse	B65F
Citotinisti y	2-7	Environmental	T12F	Camering of Bomesiic Refuse	
Chemistry	TF24		24	Water Treatment	C02
Chemish y	1124	Environmental	T13F	maler Healinelli	E01F
Chamiatry	TEO 4			Absorbing poice from reads	
Chemistry	TF24	technology Environmental	24 T14F	Absorbing noise from roads	8
Chamitata	TEO 4			Car Havy Silamassa	EOIN
Chemistry	TF24	0,	24	Gas-Flow Silencers	F01N
G	T-0 /	Environmental	T15F	-	F00.6
Chemistry	TF24	0,	24	Furnaces	F23G
		Environmental	T16F		
Chemistry	TF24	ŭ,	24	Combustion Products	F23J
		Environmental	T17F	Measuring Nuclear Or X-	
Chemistry	TF24	technology	24	Radiation	G01T
Mechanical			TO1F		
engineering	TF25	Handling	25	Manipulators	B25J
Mechanical			TO2F		
engineering	TF25	Handling	25	Packaging Machines	B65B
Mechanical		<u> </u>	TO3F		
engineering	TF25	Handling	25	Labelling Machines	B65C
			ı		·





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Mechanical			TO4F	Containers for Storage of	
engineering	TF25	Handling	25	Articles	B65D
Mechanical			T05F		
engineering	TF25	Handling	25	Transport of Storage Devices	B65G
Mechanical			T06F		
engineering	TF25	Handling	25	Handling Thin Material	B65H
Mechanical		Ŭ.	T07F		
engineering	TF25	Handling	25	Lifting	B66
Mechanical			T08F		
engineering	TF25	Handling	25	Opening Bottles	B67
Mechanical			T01F	Protection against Fire and	
engineering	TF26	Machine tools	26	Chemicals	A62D
Mechanical	1120	Machine 10013	T02F	Chemicals	AUZB
engineering	TF26	Machine tools	26	Mechanical Metal-Working	B21
Mechanical	1120	Machine 1001s	T03F	Mechanical Metal-Working	BZI
	TEO 4	AA malaina a ka ala	103F 26	AA malaina Talai	B23
engineering	TF26	Machine tools	T04F	Machine Tools	B23
Mechanical	TEO/	AA . al. t	-	C to Proceed By Printer	BO 4
engineering	TF26	Machine tools	26	Grinding and Polishing	B24
Mechanical	TEC /		T05F	- O P	DOSD
engineering	TF26	Machine tools	26	Tools Or Benches	B25B
Mechanical			T06F		
engineering	TF26	Machine tools	26	Nailing Or Stapling Tools	B25C
Mechanical			T07F		
engineering	TF26	Machine tools	26	Percussive Tools	B25D
Mechanical			T08F		
engineering	TF26	Machine tools	26	Multi-Purpose Tools	B25F
Mechanical			T09F		
engineering	TF26	Machine tools	26	Handles For Hand Implements	B25G
Mechanical			T10F		
engineering	TF26	Machine tools	26	Workshop Equipment	B25H
Mechanical			T11F		
engineering	TF26	Machine tools	26	Other Hand-Held Cutting Tools	B26B
Mechanical			T12F		
engineering	TF26	Machine tools	26	Cutting	B26D
Mechanical			T13F	- 3	
engineering	TF26	Machine tools	26	Perforating	B26F
Mechanical		77144	T14F		
engineering	TF26	Machine tools	26	Working Wood	B27
Mechanical	1120	Widefill Cools	T15F	Tronking Wood	527
engineering	TF26	Machine tools	26	Presses	B30
Mechanical	1120		T01F	Machines Or Engines for +	B30
	TF27		27	_	F01B
engineering	IFZ/	turbines	T02F	Displacement	טוטו
Mechanical	TEO 7	Engines, pumps,		Biotom Marshine - On France	E01C
engineering	TF27	turbines	27	Piston Machines Or Engines	F01C
Mechanical	TE0 7	Engines, pumps,	T03F		F01D
engineering	TF27	turbines	27	Displacement	F01D
Mechanical		Engines, pumps,	TO4F		
engineering	TF27	turbines	27	Steam Engine Plants	F01K
Mechanical		Engines, pumps,	T05F		
engineering	TF27	turbines	27	Cyclic Machines Or Engines	F01L
Mechanical		Engines, pumps,	T06F	_	
engineering	TF27	turbines	27	Engines	F01M
Mechanical		Engines, pumps,	TO7F	Cooling Of Machines Or	
engineering	TF27	turbines	27	Engines	FO1P
Mechanical		Engines, pumps,	T08F		
engineering	TF27	turbines	27	Combustion Engines In General	F02
Mechanical		Engines, pumps,	T09F	Propulsive Machines Or	
engineering	TF27	turbines	27	Engines For Liquids or Wind	F03
Mechanical		Engines, pumps,	T10F	Machines For Liquids Pumps	
engineering	TF27	turbines	27	Piston	F04
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Mechanical		Engines, pumps,	T11F	Generating Combustion	
engineering	TF27	turbines	27	Products Of High P Or High V	F23R
Mechanical		Engines, pumps,	T12F	Other subjects Engines and	
engineering	TF27	turbines	27	Pumps	F99Z
Mechanical		Engines, pumps,	T13F		
engineering	TF27	turbines	27	Nuclear Eng.	G21
Mechanical		Textile and	TO1F		
engineering	TF28	paper machines	28	Methofs for Clothes	A41H
Mechanical		Textile and	T02F		
engineering	TF28	paper machines	28	Repairing Footwear	A43D
Mechanical		Textile and	T03F		
engineering	TF28	paper machines	28	Production of Brushes	A46D
Mechanical		Textile and	TO4F		
engineering	TF28	paper machines	28	Working Paper	B31
Mechanical		Textile and	T05F		
engineering	TF28	paper machines	28	Printing	B41
Mechanical		Textile and	T06F		
engineering	TF28	paper machines	28	Hides Or Leather	C14B
Mechanical	20	Textile and	T07F	ggg Gr Eddillol	
engineering	TF28	paper machines	28	Threads or Fibers	D01
Mechanical	1120	Textile and	T08F	III Odds Of TIDELS	
engineering	TF28		28	Crimping of Threads or Fibers	D02
Mechanical	1120	Textile and	T09F	Crimping of filledus of fibers	D02
	TF28	paper machines	28	Shedding Mechanisms	D03
engineering Mechanical	IFZO	Textile and	T10F	Shedding Mechanisms	D03
	TF28	paper machines	28	Vaitting	D04B
engineering Mechanical	IFZO	•	711F	Knitting	D04В
	TEOO		111F 28	Dunidia a	D0.46
engineering	TF28	paper machines		Braiding	D04C
Mechanical	TEO	Textile and	T12F	AA . I. S NI I	D0.46
engineering	TF28	paper machines	28	Making Nets	D04G
Mechanical	TF0 0	Textile and	T13F	I ·	B
engineering	TF28	paper machines	28	Textile Fabrics	D04H
Mechanical		Textile and	T14F		
engineering	TF28	paper machines	28	Sewing	D05
Mechanical		Textile and	T15F	Mechanical Or Pressure	50/0
engineering	TF28	paper machines	28	Cleaning of Textile	D06G
Mechanical		Textile and	T16F	Marking Inspecting Seaming	
engineering	TF28	paper machines	28	Or Severing Textile	D06H
Mechanical		Textile and		Pleating Kilting Or Goffering	
engineering	TF28	paper machines	28	Textile	D06J
Mechanical		Textile and	T18F		
engineering	TF28	paper machines	28	Other Treatments	D06M
Mechanical		Textile and	T19F	_	
engineering	TF28	paper machines	28	Dyeing Or Printing Textiles	D06P
Mechanical		Textile and	T20F		
engineering	TF28	paper machines	28	Decorating Textiles	D06Q
Mechanical		Textile and	T21F		
engineering	TF28	paper machines	28	Paper Making	D21
Mechanical		Textile and	T22F	Other Subjects textiles and	
engineering	TF28	paper machines	28	papers	D99Z
Mechanical		Other special	T01F		
engineering	TF29	machines	29	Soil Working	A01B
Mechanical		Other special	T02F		
engineering	TF29	machines	29	Planting	A01C
Mechanical		Other special	T03F		
engineering	TF29	machines	29	Harvesting	A01D
Mechanical	·	Other special	T04F		
engineering	TF29	machines	29	Harvested Produce	A01F
Mechanical		Other special	T05F		
engineering	TF29	machines	29	Horticulture	A01G
gcc.ing			-/		





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Mechanical		Other	special			
engineering	TF29	machines		29	Production of Dairy Products	A01J
Mechanical		Other	special			
engineering	TF29	machines		29	Husbandry	A01K
Mechanical		Other	special	T08F		
engineering	TF29	machines		29	Shoeing Of Animals	A01L
Mechanical		Other	special	T09F		
engineering	TF29	machines	-	29	Traps for animals	A01M
Mechanical		Other	special	T10F	-	
engineering	TF29	machines	•	29	Baking	A21B
Mechanical		Other	special	T11F		
engineering	TF29	machines	•	29	Dough	A21C
Mechanical		Other	special	T12F		
engineering	TF29	machines	•	29	Treatment of Meat	A22
Mechanical		Other	special	T13F		
engineering	TF29	machines		29	Process of Harvests	A23N
Mechanical	-	Other	special			
engineering	TF29	machines		29	Working Of Foodstuffs	A23P
Mechanical		Other	special	T15F	9	-
engineering	TF29	machines	5F 0 0101	29	Preparing Grain and Fruit	B02B
Mechanical		Other	special	T16F	<u> </u>	
engineering	TF29	machines	op o c. a.	29	Working Cement or Stone	B28
Mechanical		Other	special		Transing Comercia of Crono	
engineering	TF29	machines	special	29	Working of Plastics	B29
Mechanical	1127	Other	special		Other Micro and Nao	527
engineering	TF29	machines	special	29	Technology	B99Z
Mechanical	1127	Other	special	T19F	10cmiology	3772
engineering	TF29	machines	special	29	Manufacturind or Shaping	C03B
Mechanical	1127	Other	special		Manoracionna or snaping	COOD
engineering	TF29	machines	special	29	Processes Of Compounding	C081
Mechanical	1127	Other	special	T21F	Trocesses Or Compounding	6003
engineering	TF29	machines	special	29	Pitching Machines	C12L
engineering	1127	machines		27	Reducing the size of material	CIZE
Mechanical		Other	special	T22F	from which sugar is to be	C13B
engineering	TF29	machines	special	29	extracted	5
engineering	1127	machines		27	Expressing water from	
Mechanical		Other	special	T23F	,	C13B
engineering	TF29	machines	special	29	been extracted	15
Mechanical	11 2 7	Other	special		Evaporating or boiling sugar	
engineering	TF29	machines	special	29	juices	25
Mechanical	11 2 7	Other	special		Cutting machines specially	C13B
engineering	TF29	machines	special	29	adapted for sugar	45
Mechanical	11 4 7	Other	special	T26F	adapted for sugar	73
engineering	TF29	machines	special	29	Sugar Production	C13C
Mechanical	11 4 7	Other	cnce:=l	T27F	Jogui Houdelloll	C13C
	TE20	machines	special	12/F 29	Evaporation Apparatus	C13G
engineering Mechanical	TF29	Other	cnce:=l	T28F	Evaporation Apparatus	CISG
	TE20		special		Cutting of Sugar	C13H
engineering	TF29	machines	-m1 -1	29	Cutting of Sugar	СІЗП
Mechanical	TEOO	Other	special	T29F	\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\	 E41
engineering	TF29	machines	-m 1	29	Weapons	F41
Mechanical	TEOO	Other	special	T30F	Amana misiana Blassii	_{E42}
engineering	TF29	machines		29	Ammunitions Blasting	F42
AA		Thermal	i	TO 15		
Mechanical	TEGG	processes	and	T01F	Clarence of the control of the contr	
engineering	TF30	apparatus		30	Steam generation	F22
.		Thermal		T0.05		
Mechanical	TE0 6	processes	and	TO2F		F00B
engineering	TF30	apparatus		30	Solid Fuel	F23B
Mechanical		Thermal	_	TO3F	,	
engineering	TF30	processes	and	30	Fluent Fuel	F23C





AND INNOVAT	ION POLI			1	_		
		apparatus					
		Thermal					
Mechanical		processes	and	TO4F			
engineering	TF30	apparatus		30	Burners	F23D	
		Thermal					
Mechanical		processes	and	T05F			
engineering	TF30	apparatus		30	Grates	F23H	
		Thermal					
Mechanical		processes	and	T06F	Feeding Fuel To Combustion		
engineering	TF30	apparatus		30	Apparatus	F23K	
gg		Thermal			, , , , , , , , , , , , , , , , , , ,		
Mechanical		processes	and	T07F			
engineering	TF30	apparatus		30	Air Supply	F23L	
gg		Thermal			/ серр./		
Mechanical		processes	and	T08F			
engineering	TF30	apparatus	unu	30	Combustion Chambers	F23M	
crigineering	1100	Thermal		50	Compositori Cirampers	120/11	
Mechanical		processes	and	T09F			
engineering	TF30	apparatus	unu	30	Controlling Combustion	F23N	
Grigineering	1130	Thermal		50	Controlling Compositori	12011	
AA a ala ami a al			اء مدده	T10F			
Mechanical	TE20	processes	and		Extinguishing Dovies	E23O	
engineering	TF30	apparatus		30	Extinguishing Devices	F23Q	
AA a al! !		Thermal	a I	T11F			
Mechanical	TEOO	processes	and	TIIF		F0.4	
engineering	TF30	apparatus		30	Domestic Stoves For Solid Fuels	F24	
l.,		Thermal					
Mechanical		processes	and	T12F			
engineering	TF30	apparatus		30	Refrigeration Systems	F25B	
		Thermal					
Mechanical		processes	and	T13F			
engineering	TF30	apparatus		30	Ice	F25C	
		Thermal					
Mechanical		processes	and	T14F			
engineering	TF30	apparatus		30	Furnaces ovens	F27	
		Thermal					
Mechanical		processes	and	T15F			
engineering	TF30	apparatus		30	Heat Exchange	F28	
Mechanical		Mechanical		TO1F			
engineering	TF31	elements		31	Fluid Pressure Actuator	F15	
Mechanical		Mechanical		T02F			
engineering	TF31	elements		31	Engineering Elts or Units	F16	
Mechanical	1	Mechanical		T03F	Stroring Distributing Non		
engineering	TF31	elements		31	Solids	F17	
Mechanical	1	Mechanical		T04F			
engineering	TF31	elements		31	Mechanical Control Systems	G05G	
Mechanical	1			TO1F	2		
engineering	TF32	Transport		32	Vehicles	B60	
Mechanical	52			T02F	. c.neiss		
engineering	TF32	Transport		32	Railways	B61	
Mechanical	1132	ii ulispul i		T03F	Kullwuys	501	
engineering	TF32	Transport		32	Land Vehicles	B62	
Mechanical	1132	ii uiispoi i		T04F	Lana venicies	502	
	TESS	Transact		32	China	D42D	
engineering	TF32	Transport			Ships	B63B	
Mechanical	TEGG			T05F	La calcada CM	D/36	
engineering	TF32	Transport		32	Launching of Vessels	B63C	
Mechanical				T06F		D/00	
engineering	TF32	Transport		32	Weapons on Vessels	B63G	
Mechanical	1_	_		T07F		_	
engineering	TF32	Transport		32	Marine Propulsion	B63H	
Mechanical	TF32	Transport		T08F	Auxilaries on Vessel	B63J	
			_				





AND INNOVALI	T	C1 010 D120	20		
engineering			32		
Mechanical			TO9F		
engineering	TF32	Transport	32	Aircraft	B64
			TO1F	Furniture and Domestic	
Other fields	TF33	Furniture, games	33	Equipment	A47
		, 3	TO2F		
Other fields	TF33	Furniture, games	33	Sports and Games	A63
O III OI II OIGS		Other consumer	TO1F	oports una Guines	7.00
Other fields	TF34		34	Tobacco	A24
Officer fields	1134		T02F	TODUCCO	AZ4
0.1 ()	TEO 4	Other consumer		ci : .	A 41D
Other fields	TF34	0	34	Shirts	A41B
		Other consumer	T03F		
Other fields	TF34	goods	34	Corsets	A41C
		Other consumer	TO4F		
Other fields	TF34	goods	34	Outerwear	A41D
		Other consumer	T05F		
Other fields	TF34	goods	34	Suspenders	A41F
		Other consumer	T06F	Собранцено	7.1.11
Other fields	TF34		34	Wigs	A41G
Office fields	1134		T07F	Wigs	A410
Other Cold	TE2.4			111	
Other fields	TF34	v	34	Headwear	A42
		Other consumer	T08F		
Other fields	TF34	9	34	Footwear	A43B
		Other consumer	TO9F		
Other fields	TF34	goods	34	Laces	A43C
		Other consumer	T10F		
Other fields	TF34		34	Fasteners and Braselets	A44
O III OI II OIGS	1104	Other consumer	T11F	rasionors and Brasolors	7,4-4
Other fields	TF34		34	Hand or Travalling Articles	A45
Officer fields	1134	•		Hand or Travelling Articles	A45
	,	Other consumer	T12F		
Other fields	TF34		34	Brushes	A46B
		Other consumer	T13F		
Other fields	TF34	O .	34	Methods For Life-Saving	A62B
		Other consumer	T14F	Other Life saving and	
Other fields	TF34	goods	34	Amusement	A99Z
		Other consumer	T15F		
Other fields	TF34		34	Bookbinding	B42
		Other consumer	T16F	g	
Other fields	TF34	_	34	Writing Implements	B43
Office fields	1134	- 1		Willing implements	B43
Other Eld	TEO 4	Other consumer	T17F	Dogowative Auto	
Other fields	TF34	•	34	Decorative Arts	B44
		Other consumer	T18F		
Other fields	TF34	0	34	Saddlery and Upholstery	B68
		Other consumer	T19F		
Other fields	TF34	goods	34	Trimmings	D04D
		Other consumer	T20F		
Other fields	TF34		34	Laundering	D06F
		Other consumer	T21F	<u> </u>	
Other fields	TF34		34	Wall Floor Covering	D06N
551 110103		Other consumer	T22F	Hoor Coroning	
Other fields	TE2 4			Pono non cloatria anti-	D07
Other fields	TF34	0	34	Rope non electric cable	טט/
		Other consumer	T23F		FO.F.D.
Other fields	TF34	•	34	Cooling Or Freezing Apparatus	F25D
		Other consumer	T24F		
Other fields	TF34	goods	34	Organs Harmoniums	G10B
		Other consumer	T25F		
Other fields	TF34	goods	34	Pianos	G10C
		Other consumer	T26F		
Other fields	TF34		34	Musical Instruments	G10D
	1	-			
Other fields	TF34	Other consumer	T27F	Automatic Musical Instruments	G10F





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		goods	34		
		Other consumer	T28F		
Other fields	TF34	goods	34	Aids For Music	G10G
		Other consumer	T29F	Electrophonic Musical	
Other fields	TF34		34	Instruments	G10H
		Other consumer	T30F		
Other fields	TF34	goods	34	Sound-Producing Devices	G10K
			TO1F		
Other fields	TF35	Civil engineering	35	Permanent ways	E01B
			T02F	Surfaces for roads and sport	
Other fields	TF35	Civil engineering	35	grounds	E01C
			T03F		
Other fields	TF35	Civil engineering	35	Bridges	E01D
			TO4F		
Other fields	TF35	Civil engineering	35	Platforms or refuge islands	E01F 1
			T05F		E01F
Other fields	TF35	Civil engineering	35	Landing for helicopters	3
			T06F		E01F
Other fields	TF35	Civil engineering	35	Draining of roads	5
			T07F		E01F
Other fields	TF35	Civil engineering	35	drifts	7
			T08F		E01F
Other fields	TF35	Civil engineering	35	Road signs or traffic signals	9
			T09F	Sensitive and restricitng and	
Other fields	TF35	Civil engineering	35	safety in roads	E01F 1
			T10F		
Other fields	TF35	Civil engineering	35	Street Land Cleaning	E01H
			T11F	Hydraulic Eng. Foundations	
Other fields	TF35	Civil engineering	35	Soil-Shifting	E02
			T12F		
Other fields	TF35	Civil engineering	35	Water supply sewerage	E03
			T13F		
Other fields	TF35	Civil engineering	35	Building	E04
			T14F		
Other fields	TF35	Civil engineering	35	Locking Safing	E05
			T15F		
Other fields	TF35	Civil engineering	35	Openings in Building Ladder	E06
			T16F		
Other fields	TF35	Civil engineering	35	Earth Or Rock Drilling	E21
			T17F		
Other fields	TF35	Civil engineering	35	Other Subjects Building	E99Z

Appendix 4: Building description for International Patent Classification

Patents have fine grained information to describe the technologies that are combined by the applications. The International Patent Classification (IPC) is a hierarchical <u>patent</u> <u>classification</u> system used to classify the content of <u>patents</u> in a uniform manner.

with approximately 70 000 subdivisions ¹¹. Each subdivision is described with a short text that we have collected.

Each classification symbol is of the form «A01B 1/00. The first letter represents the "section" consisting of a letter from A ("Human Necessities") to H ("Electricity"). Combined with a two digit number, it represents the "class" (class A01 represents "Agriculture; forestry; animal

¹¹ https://www.wipo.int/classifications/ipc/en/





husbandry; trapping; fishing"). The final letter makes up the "subclass" (subclass A01B represents "Soil working in agriculture or forestry; parts, details, or accessories of agricultural machines or implements, in general"). The subclass is followed by a one-to-three-digit "group" number, an oblique stroke and a number of at least two digits representing a "main group" or "subgroup" (reference https://en.wikipedia.org/wiki/International Patent Classification)

For each classification symbol we have concatenated the description of all levels, rebuilding the IPC hierarchy. Each patent receives the concatenated description of different levels of its IPC codes.

A01B 1/00will be described as: Soil working in agriculture or forestry; parts, details, or accessories of agricultural machines or implements, in general. Agriculture; forestry; animal husbandry; trapping; fishing. Human Necessities.

Details on the used methodology is given in: https://github.com/cortext/PATSTAT/tree/master/nomenclatures/ipc descriptions





Appendix 5: Data model of PATSTAT2017

The data model shown below is the model of the PATSTAT 2017 database.

